

Nishantha Sampath Punchi Hewage

Promoting a Second-Tier Protection Regime for Innovation of Small and Medium-Sized Enterprises in South Asia

The Case of Sri Lanka



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Table of Contents

List of Figures	13
List of Tables	15
Abbreviations	17
1. Introduction and Background	19
1.1. Research Statement	19
1.1.1. Objectives	23
1.1.2. Research Problem	24
1.1.3. Hypothesis and Research Questions	24
1.1.4. Research Methodology	26
1.1.5. How does this Research contribute to the Legal Science?	26
1.1.6. Limitations	27
1.2. Preliminary Thoughts and Definitions	27
1.2.1. Invention and Innovation	27
1.2.2. Second-Tier Protection	31
1.2.3. A Developing Country	33
1.2.4. SMEs	34
1.3. Sri Lankan Innovation Landscape	38
1.3.1. Specific Characteristics of the Sri Lankan Innovation Landscape	40
1.3.2. The Statistical Story	41
1.3.3. A Lack of Incentives for Innovation?	46
1.4. TK-based Innovation	50
1.4.1. What is it?	51
1.4.2. A particular Need for Protection?	51
1.5. The South Asian Scenario	53
1.6. Overview of Second-Tier Protection	59
1.6.1. Common Elements and Divergence	60

1.6.2.	The Rationale for STP Systems	64
1.6.3.	Pros and Cons of an STP Regime	65
1.6.4.	Policy Considerations to be applied by Legislators	66
1.7.	International Legal Framework	67
1.7.1.	Obligations under the Paris Convention	68
1.7.2.	Obligations under TRIPS Agreement	72
1.7.3.	Other Patent Treaties and Agreements	73
1.7.4.	Flexibilities and Policy Space	74
1.8.	Conclusion	75
2.	Incremental Innovations and the Existing IPR System in Sri Lanka	77
2.1.	Introduction	77
2.1.1.	Philosophical Underpinnings of IP	79
2.2.	Patent Protection in Sri Lanka	81
2.2.1.	A Brief Overview	81
2.2.2.	The Origin of the Patent System	83
2.2.3.	The Introduction of Patent Law in Sri Lanka	84
2.2.4.	Which Inventions are Patentable?	86
2.2.5.	Conditions of Patentability	87
2.2.6.	The Concept of Novelty	87
2.2.7.	Inventive Step	90
2.2.8.	Industrial Applicability	96
2.2.9.	The Rights of the Owner of a Patent	97
2.2.10.	Empirical Analysis of Sri Lankan Patent System	99
2.2.11.	Use of the Patent System	105
2.2.12.	Adequacy of the Existing Patent Regime	110
2.3.	Design Protection in Sri Lanka	112
2.3.1.	Introduction	112
2.3.2.	Overview of Sri Lankan Law	113
2.3.3.	Empirical Analysis	115
2.3.4.	Is Design Protection an Alternative to a Second-Tier Protection Regime?	118
2.4.	Comparative view of Different IPRs in Sri Lanka	120
2.5.	Conclusion	121

3. Incentive Mechanisms for Incremental and Minor Innovations under Unfair Competition Law and Trade Secrets Law in Sri Lanka	124
3.1. Unfair Competition Law	124
3.1.1. Introduction	125
3.1.2. The International Dimension	127
3.1.3. Current Legal Regime against Unfair Competition in Sri Lanka	130
3.1.4. Development of the Case-Law	131
3.1.5. How Effective is Unfair Competition Law to Protect Sub-patentable Innovation?	133
3.1.6. Passing-off Action	134
3.1.7. Current Status of Passing-off Action in Sri Lanka	138
3.1.8. Conclusion	139
3.2. Trade Secrets Protection	141
3.2.1. Background and the Emergence of Trade Secret Law	141
3.2.2. What is a Trade Secret?	142
3.2.3. Current Protection of Trade Secrets in the IP Act	144
3.2.4. Common Law Action for Breach of Confidence	145
3.2.5. Other Legal Regimes: Contract and Labour Law	147
3.2.6. Empirical Evidence	149
3.2.7. Why is Trade Secrets Protection so Attractive?	150
3.2.8. Difficulties and Challenges for SMEs	152
3.2.9. Conclusion	156
4. Second-Tier Patent Protection in other Jurisdictions: Legislative Examples from outside South Asia	158
4.1. Experience from Developed Countries	159
4.1.1. Germany	159
4.1.1.1. A Brief Historical Overview	159
4.1.1.2. Main Features of the Current UM System	161
4.1.1.3. Empirical Analysis and Policy Implications	166
4.1.1.4. Lessons from Germany	171
4.1.2. Australia	172
4.1.2.1. Main Features of Current Innovation Patents	175

4.1.2.2. Empirical Analysis and Policy Implications	181
4.1.2.3. Lessons from Australia	187
4.2. Experience from Emerging and Developing Economies	188
4.2.1. China	188
4.2.1.1. Current System of Utility Model Protection	189
4.2.1.2. Empirical Analysis and Policy Implications	193
4.2.1.3. Critique and New Developments	197
4.2.1.4. Lessons from China	199
4.2.2. Malaysia	201
4.2.2.1. Main Features of the UM System	201
4.2.2.2. Empirical Analysis of the UI System	205
4.2.2.3. Lessons from Malaysia	210
4.2.3. Kenya	211
4.2.3.1. Protection under the Current System	212
4.2.3.2. Empirical Analysis	213
4.2.3.3. Lessons from Kenya	218
5. South Asian Region and Second-Tier Protection	220
5.1. Indian Perspectives	222
5.1.1. Empirical Analysis of the Indian Patent System	225
5.1.2. Protection of Incremental Innovations in India	230
5.1.3. DIPP Discussion Paper	231
5.1.4. Does India need such a System?	237
5.1.5. What happens Next?	239
5.2. Pakistani Perspectives	240
5.2.1. The Statistical Story	241
5.2.2. Protection for Incremental Innovations in Pakistan	244
5.2.3. Recent Initiatives	245
5.3. Whether and to what extent are these Experiences applicable to Sri Lanka?	246
5.3.1. Conclusion	248
6. Designing a Second-Tier Protection Regime for Sri Lanka	250
6.1. Arguments for introducing an STP in Sri Lanka	251
6.2. Arguments against such an STP Regime	261
6.3. Design and Structure	263

6.4. Core Elements	265
6.4.1. Protected Subject-Matter/Scope of Protection	265
6.4.2. Standard of Novelty	266
6.4.3. Inventive Step Requirement	267
6.4.4. Elevated Utility Requirement	268
6.4.5. Granting Procedure	270
6.4.6. Duration of Protection	271
6.4.7. Exceptions and Limitations	272
6.5. Prosecution and Enforcement	272
6.6. Interface with other IPR Systems	273
6.7. Guarding against Abuse	274
6.8. Domestic IP Infrastructure (IP Office, Courts, Professionals)	275
6.9. TK-based Innovation and Second-Tier Protection	277
6.9.1. Why is such a Form of Protection Important?	278
6.9.2. Herbal and Cosmetic Product Sector	279
6.9.3. Traditional Medicines: a Potential Candidate for Protection?	280
6.10. Conclusion	283
7. Recommendations and Policy Options for the South Asian Region	285
7.1. Policy Options	287
7.1.1. Sri Lanka	289
7.1.2. India and Pakistan	291
7.1.3. Other South Asian Countries	292
7.2. General Recommendations and Observations	293
7.3. Conclusion	296
7.4. Outlook	298

8. Summary (in German)	299
Teil 1: Einleitung und Hintergrund	299
Teil 2: Inkrementelle Innovationen und das bestehende Immaterialgüterschutzsystem in Sri Lanka	300
Teil 3: Anreizmechanismen für inkrementelle und kleinere Innovationen im Lauterkeitsrecht und im Recht der Geschäftsgeheimnisse in Sri Lanka	302
Teil 4: Mehrstufige Schutzrechtssysteme in anderen Jurisdiktionen: Gesetzgebungsbeispiele aus Ländern von außerhalb Südasiens	304
Erfahrungen aus entwickelten Ländern	304
Erfahrungen aus Deutschland	304
Erfahrungen aus Australien	305
Erfahrungen aus aufstrebenden Ländern und aus Entwicklungsländern	306
Erfahrungen aus China	306
Erfahrungen aus Malaysia	307
Erfahrungen aus Kenia	308
Teil 5: Die Region Südostasien und zweistufige Schutzsysteme	309
Die Perspektive Indiens	309
Die Perspektive Pakistans	311
Die Übertragbarkeit dieser Erfahrungen auf Sri Lanka	312
Teil 6: Der Entwurf eines zweistufigen Schutzrechtsregimes für Sri Lanka	313
Teil 7: Empfehlungen und rechtspolitische Optionen für die Region Südostasien	315
Ausblick	316
Bibliography	317

List of Figures

Figure 1.1:	TK-based Innovation	50
Figure 2.1:	Trends in Patent Filings	100
Figure 2.2:	Trends in Patent Filings: Resident and Non-Resident	101
Figure 2.3:	Trends in Patent Grants	102
Figure 2.4:	Trends in Patent Grants: Resident and Non-Resident	103
Figure 2.5:	Who owns Sri Lankan Patents?	105
Figure 2.6:	Use of Patent System by SMEs	108
Figure 2.7:	Trends in Design Applications	116
Figure 2.8:	Trends in Design Applications and Registration	117
Figure 2.9:	Trends in Patent, Design and Trademark Applications	120
Figure 4.1:	Trends in Patent Applications, 2000-2010	167
Figure 4.2:	Trends in Utility Model Applications, 2000-2010	169
Figure 4.3:	Trends in Patent Applications, 2000-2010	183
Figure 4.4:	Trends in Innovation Patent Applications, 2000-2010	184
Figure 4.5:	Growth in Patent Applications, 2000-2011	195
Figure 4.6:	Invention, Utility and Design Patent Grants, 2011	196

List of Figures

Figure 4.7:	Trends in Patent Applications, 2000-2011	206
Figure 4.8:	Trends in Utility Innovation Applications, 2000-2011	208
Figure 4.9:	Growth in Utility Innovation Applications, 2003-2011	208
Figure 4.10:	Trends in Patent Applications, 2002-2010	214
Figure 4.11:	Trends in Utility Model Applications, 2002-2010	215
Figure 5.1:	Trends in Patent Applications, 2003-2010	227
Figure 5.2:	Trends in Patent Grants, 2003-2010	228
Figure 5.3:	A Comparative View on Patent Applications and Grants from 2003-2010	229
Figure 5.4:	Patent Applications by Resident and Non-resident from 2000-2010	242
Figure 5.5:	A Comparative View of Patent Applications and Grants, 2005-2010	243
Figure 6.1:	The Share of High Tech Exports out of the Total Manufactured Exports, 2010	253
Figure 6.2:	Views of Sri Lankan SMEs on Possible UM System	260

List of Tables

Table 1.1:	Industrial Property Statistics for Patents	43
Table 1.2:	A Comparative View of R&D Expenditure of GDP in Selected Countries	45
Table 1.3:	Comparison of IP Statistics of South & East Asian Countries, 2009-2010	54
Table 1.4:	Trends in Patent Applications and Grants in India	56
Table 1.5:	Trends in Patent Applications and Grants in Pakistan	57
Table 1.6:	Comparison of Second-Tier Protection Regimes in Selected Countries	62
Table 2.1:	Industrial Design Applications and Registrations	115
Table 4.1:	Patent Applications, 2000-2010	167
Table 4.2:	Utility Model Applications, 2000-2010	169
Table 4.3:	A Snapshot View of Standard, Petty and Innovation Patents	181
Table 4.4:	Patent Applications, 2000-2010	182
Table 4.5:	Innovation Patent Applications, 2000-2010	184
Table 4.6:	Innovation Patents Granted by Calendar Year	186
Table 4.7:	Applications and Grants for Three Kinds of Patents by Calendar Year	194
Table 4.8:	Chinese Versus Foreign Utility and Invention Patent Applications	195
		15

List of Tables

Table 4.9:	Patent Applications, 2002-2011	205
Table 4.10:	Utility Innovation Applications, 2003-2011	207
Table 4.11:	Patent Applications, 2003-2010	214
Table 4.12:	Utility Model Applications, 2002-2010	215
Table 5.1:	Patent Applications Received from 2003-2010	226
Table 5.2:	Patent Grants from 2003-2010	228
Table 5.3:	Patent Applications and Grants at IPO Pakistan, 2004-2010	242
Table 5.4:	Ranking of Competitive Industrial Performance (CIP) Index 2011	247
Table 5.5:	A Comparative View of Medium and High-Technology Goods Exports	247

Abbreviations

ACIP	Advisory Council of Intellectual Property
AIPPI	International Association for the Protection of Intellectual Property
ARIPO	African Regional Industrial Property Organization
ASIAN	Association of Southeast Asian Nations
CBD	Convention on Biodiversity
CGPDTM	Controller General of Patents, Designs and Trademarks
DPMA	Deutsches Patent- und Markenamt (German Patent and Trademark Office)
EPC	European Patent Convention
EPO	European Patent Office
EU	European Union
FDI	Foreign Direct Investment
FICCI	Federation of India Chambers of Commerce and Industry
FTC	Foreign Technology Collaboration
GATT	General Agreement on Trade and Tariffs
GDP	Gross Domestic Production
GERD	Gross Expenditure on Research and Development
GNE	Gross National Expenditures
ICT	Information and Communication Technologies
IIC	International Review of Industrial Property & Copyright Law
IIP	Institute of Intellectual Property (Japan)
IP	Intellectual Property
IPAC	Industrial Property Advisory Council
IPC	International Patent Classification
IPO	The Intellectual Property Organization of Pakistan
IPR	Intellectual Property Rights
IPRIA	Intellectual Property Research Institute of Australia
ISA	International Search Authorities
ISIC	International Standard Industrial Classification
ISR	International Search Report

Abbreviations

JIPA	Japan Intellectual Property Association
JPO	Japan Patent Office
KIPI	Kenya Intellectual Property Institute
KIPO	Korean Intellectual Property Office
MNCs	Multinational Corporations
MyIPO	Intellectual Property Cooperation of Malaysia
NGO	Non Governmental Organization
NIPO	National Intellectual Property Office of Sri Lanka
NLR	New Law Reports (Sri Lanka)
NSF	National Science Foundation
OAPI	African Intellectual Property Organisation
OECD	Organisation for Economic Co-operation and Development
PCT	Patent Cooperation Treaty
SIPO	State Intellectual Property Office of People's Republic of China
SMEs	Small and Medium Sized Enterprises
SMMEs	Small, Medium and Micro Enterprises
Sri LR	Sri Lanka Law Reports
STP	Second-Tier Protection
TK	Traditional Knowledge
TKDL	Traditional Knowledge Digital Library
TRIPS	Trade Related Aspects of Intellectual Property Rights
UNIDO	United Nations Industrial Development Organization
UM	Utility Models
UI	Utility Innovations
US	United States
WIPO	World Intellectual Property Organization
WTO	World Trade Organization